

Exam #3 - Practice

Instructions:

1. **Read** every problem CAREFULLY!
2. Make sure your answer addresses **each part** of the problem.
3. Make sure your answer is clearly marked by a circle or **box around the answer**.
4. Be sure to include the **proper units and 3 significant figures** with your answer.
5. You may use a calculator for basic calculations.

Potentially Useful Information (continues on next page)

Constants

$$k_B = 8.617 \times 10^{-5} \text{ eV/K}$$

$$= 1.381 \times 10^{-23} \text{ J/K}$$

$$h = 6.626 \times 10^{-34} \text{ J}\cdot\text{s}$$

$$m_e = 9.11 \times 10^{-31} \text{ kg}$$

$$N_A = 6.022 \times 10^{23} \text{ atoms/mole}$$

$$R = 8.3145 \text{ J/(K}\cdot\text{mol)}$$

$$c = 3.00 \times 10^8 \text{ m/s}$$

$$e = 1.60 \times 10^{-19} \text{ C}$$

$$(4\pi\epsilon_0)^{-1} = 8.987 \times 10^9 \text{ N}\cdot\text{m}^2\cdot\text{C}^{-2}$$

$$1.00 \text{ eV} = 1.60 \times 10^{-19} \text{ J}$$

Basics

atomic concentration = (mass density) × (Avagadro's number) / (atomic weight)

$$\rho = \frac{\sum (\text{Number of atoms of given type in unit cell} \times \text{Atomic mass of this type})}{\text{Volume of unitcell}}$$

$$PV = \left(\frac{N}{N_A} \right) RT = Nk_B T$$

$$L = L_0 [1 + \lambda(T - T_0)]$$

$$n_v = N \exp\left(-\frac{E_v}{kT}\right)$$

$$D = D_0 \exp\left(-\frac{E_A}{kT}\right)$$

$$L_{rms} = \sqrt{2Dt}$$

$$\rho = \rho_0 [1 + \alpha_0 \Delta T]$$

$$\rho_{alloy} \alpha_{alloy} = \rho_{pure} \alpha_{pure}$$

$$\rho_{alloy} = \rho_{pure} + CX(1-X)$$

$$P = IV = I^2 R = V^2 / R$$

$$V(r) = \frac{-1}{4\pi\epsilon_0} \frac{e^2}{r}$$

Quantum Mechanics

$$KE_{\max} = hf - \phi$$

$$-\frac{\hbar^2}{2m}\nabla^2\psi + V\psi = E\psi$$

$$E_{\text{ph}} = hf = hc/\lambda$$

$$E_n = \frac{\hbar^2 n^2}{8m_e a^2}$$

$$p = h/\lambda$$

$$\Delta x \Delta p \geq \hbar/4\pi$$

$$E_{n_x, n_y, n_z} = \frac{\hbar^2 \pi^2}{2m} \left(\frac{n_x^2}{l_x^2} + \frac{n_y^2}{l_y^2} + \frac{n_z^2}{l_z^2} \right)$$

Semiconductors

$$f(E) = \frac{1}{1 + e^{\frac{E-E_F}{k_B T}}}$$

$$\text{Flux } (\Gamma_{\text{ph}}) = \# / (\text{area} \times \text{time}) = \text{Intensity} / (hf) = I\lambda / (hc)$$

$$\sigma = en\mu_e + ep\mu_h$$

$$\lambda = v\tau$$

$$\tau_{e,h} = \frac{\mu_{e,h} m_{e,h}^*}{e}$$

$$m_e^* = \hbar^2 \left(\frac{d^2 E}{dk^2} \right)^{-1}$$

$$N_c = 2 \left(\frac{2\pi m_e^* kT}{h^2} \right)^{3/2}$$

$$N_v = 2 \left(\frac{2\pi m_h^* kT}{h^2} \right)^{3/2}$$

$$n_i = (N_c N_v)^{1/2} e^{-\frac{E_g}{2kT}}$$

$$np = n_i^2$$

Problem 1: Carrier Statistics Revisited

Consider the valence electrons in the 3s-band of Mg at 300 K. The density of states in metals is given as

$$g(E) = (8\pi\sqrt{2})\left(\frac{m_e^*}{h^2}\right)^{3/2}E^{1/2}$$

where the effective mass of electrons in the 3s-band of Mg is $1.30m_e$.

- Since the band is roughly filled, integrate $g(E)$ from the bottom of the band ($E=0$) to the top of the band (E_{3s}) to determine an expression for the total number of states within the band?
- Given a value of E_{3s} of 11.5 eV (hint: use SI units for the calculation: $E_{3s} = 1.84 \times 10^{-18}$ J, then convert to cm^{-3}), what is the total number of states within the band (in cm^{-3})?
- Given that Mg has a valence of 2 and a density of 1.738 g cm^{-3} , what is the concentration of valence electrons in Mg? (hint: the atomic weight for Mg is on the Periodic Table).

Now consider the electrons in the conduction band of intrinsic Si at 300 K. The conduction band electron density of states, N_c , and concentration, n , are given, respectively by

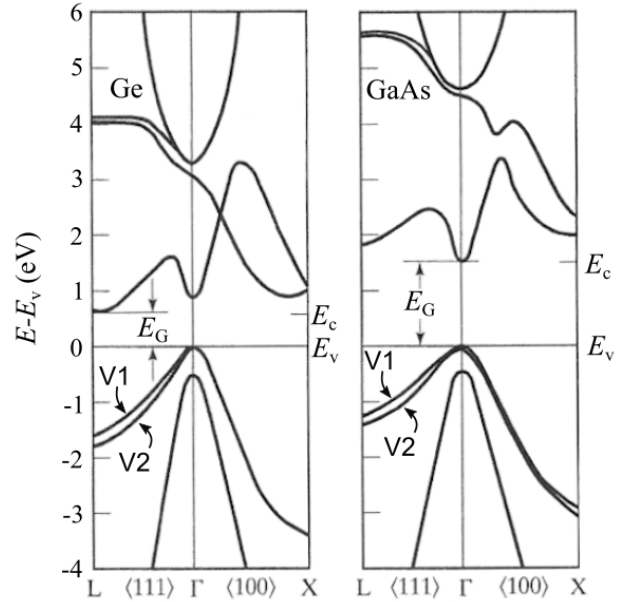
$$N_c = 2\left(\frac{2\pi m_e^* kT}{h^2}\right)^{3/2} \quad \text{and} \quad n = N_c e^{-\frac{E_c - E_F}{kT}}.$$

- Given the density of states effective mass of conduction band electrons in Si of $1.08m_e$, what is the value of the density of states, N_c , in the conduction band of Si at 300 K (in cm^{-3})?
- The band gap of Si is 1.10 eV. What is electron concentration (in cm^{-3}) in the conduction band of Si at 300 K (hint: assume the Fermi energy is mid gap)?
- Based on your results from above, which statistical description (Maxwell-Boltzmann statistics or Fermi-Dirac statistics) should we use for electrons in Mg and for Si? Explain your answer by considering the probability of electrons trying to occupy the same states and the Pauli Exclusion principle.

Problem 2: $E-k$ Plots

Consider the room temperature (300 K) energy versus wave vector ($E-k$) plots shown for Ge and GaAs.

- In precise, specific language, how does one deduce the value of the band gap, E_G , from the diagrams?
- What is the numerical value of E_G for each material?
- In precise, specific language, explain how the $E-k$ plots can be used to determine whether a semiconductor is a direct or indirect band gap semiconductor.
- Are Ge and GaAs direct or indirect band gap semiconductors?
- Precisely how does one use an $E-k$ relationship to determine the effective masses for carriers in a semiconductor? (hint: there is definitely one key word your answer should include and it's not "slope")
- Are effective masses the same for electrons and holes?
- Relative to the mass of the free electron m_e , the effective masses for GaAs are given as
 $m_e^* = 0.067m_e$ for the electrons in the conduction band
 $m_{hh}^* = 0.51m_e$ for the heavy holes in the valence band
 $m_{lh}^* = 0.082m_e$ for the light holes in the valence band
 As best as you can estimate, are these values consistent with the $E-k$ plot?
- Which bands are the "heavy holes" and which are the "light holes"?
- Since E is proportional to k^2 , one might expect the $E-k$ relationships to be symmetric about the zone center (Γ point, $k = 0$). Why are these $E-k$ plots not symmetric about Γ ?



Problem 3: Intrinsic and Extrinsic Semiconductors

For the III-V semiconductor GaAs, $E_g = 1.42$ eV, $N_c = 4.40 \times 10^{17}$ cm⁻³, $N_v = 7.70 \times 10^{18}$ cm⁻³, $\mu_e = 8800$ cm² V⁻¹ s⁻¹, $\mu_h = 400$ cm² V⁻¹ s⁻¹, $m_e^* = 0.067m_e$, and $m_h^* = 0.500m_e$.

- a. Calculate the intrinsic carrier concentration (in cm⁻³) at 300 K.
- b. Calculate the intrinsic resistivity (in Ω cm) at 300 K.
- c. Now consider doping GaAs with Si. If we want an p-type GaAs, which element must Si replace in GaAs?
- d. If we dope GaAs with Si to a p-type dopant concentration of $N_a = 4.41 \times 10^{12}$ cm⁻³, what is the resulting electron concentration (in cm⁻³) and resistivity (in Ω cm) at 300 K?
- e. If instead we doped GaAs with Si to an n-type dopant concentration of $N_d = 4.41 \times 10^{12}$ cm⁻³, will its resistivity be higher, lower, or the same as you found in part (d)? Can you answer this without calculating the resistivity explicitly? Explain.
- f. (Extra credit) Now consider an intrinsic (undoped) GaAs crystal at 300K that is being illuminated with 1.00 second long pulses from a Ti:sapphire laser ($\lambda = 800$ nm). The crystal has dimensions of 1 cm \times 1 cm \times 1 cm, and the incident light is uniformly and completely absorbed over the volume of the crystal. Assuming that each absorbed photon creates an electron-hole pair, what laser intensity (in μ W/cm²) is required such that the resistivity of the illuminated intrinsic GaAs will equal the resistivity of the doped GaAs from part (d)?